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Assistant Commissioner for Patents
Washington, D.C. 20231

04/18/01
U.S. PTO

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18 April 2001

INTELLECTUAL PROPERTY LAW

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04/18/01
U.S. PTO
09/836550

Attorney Docket: P56342

Sir:

Submitted herewith is the following patent application:

Inventor: 1) DEOK-HYEON CHOE
2) JONG-HAN RHEE
3) SANG-HO JEON
4) YOUNG-BIN IM

Title: TENSION MASK FOR COLOR CRT, METHOD FOR
MANUFACTURING THE TENSION MASK, AND EXPOSURE
MASK USED IN THE MANUFACTURE OF THE TENSION
MASK

Please find attached hereto an application for patent which includes: Specification and Abstract, Claims, and a certified copy of the foreign priority document identified below:

Verified Showing of Small Entity Status: NO

Drawings: Formal drawings, 13 sheets, Figures 1-19

Claim of priority under 35 U.S.C. §119: YES

** The Republic Of Korea Application No. 2000-20994 filed on 20 April 2000.

FEE (see formula below): CHECK IS NOT ENCLOSED

Basic Fee \$355/710 \$710.00

Additional Fees:

Total number of claims in excess of 20: 13 times \$9/18 . \$234.00

Number of independent claims in excess of 3: 1 times \$40/80 \$80.00

Multiple Dependent Claims \$135/270 \$0.00

An Assignment is likewise enclosed: Recording Fee \$40 . \$0.00

Filing Non-English specification \$0.00

TOTAL FEES FOR THE ABOVE APPLICATION \$1,024.00

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Docket No.: P56342

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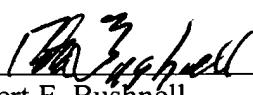
Title: **TENSION MASK FOR COLOR CRT, METHOD FOR
MANUFACTURING THE TENSION MASK, AND EXPOSURE
MASK USED IN THE MANUFACTURE OF THE TENSION
MASK**

In view of the above, it is requested that this application be accorded a filing date pursuant to 37 CFR 1.53(b).

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Respectfully submitted,



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